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Front Matter: Volume 10915

, "Front Matter: Volume 10915," Proc. SPIE 10915, Organic Photonic Materials and Devices XXI, 1091501 (10 May 2019); doi: 10.1117/12.2531136

SPIE.

Event: SPIE OPTO, 2019, San Francisco, California, United States

PROCEEDINGS OF SPIE

Organic Photonic Materials and Devices XXI

Christopher E. Tabor
François Kajzar
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Editors

5–7 February 2019
San Francisco, California, United States

Sponsored and Published by
SPIE

Volume 10915

Proceedings of SPIE 0277-786X, V. 10915

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

Organic Photonic Materials and Devices XXI, edited by Christopher E. Tabor, François Kajzar, Toshikuni Kaino,
Proc. of SPIE Vol. 10915, 1091501 · © 2019 SPIE · CCC code: 0277-786X/19/\$18 · doi: 10.1117/12.2531136

Proc. of SPIE Vol. 10915 1091501-1

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Author(s), "Title of Paper," in *Organic Photonic Materials and Devices XXI*, edited by Christopher E. Tabor, François Kajzar, Toshikuni Kaino, Proceedings of SPIE Vol. 10915 (SPIE, Bellingham, WA, 2019) Seven-digit Article CID Number.

ISSN: 0277-786X
ISSN: 1996-756X (electronic)

ISBN: 9781510624726
ISBN: 9781510624733 (electronic)

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA
Telephone +1 360 676 3290 (Pacific Time) · Fax +1 360 647 1445

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Contents

v	<i>Authors</i>
vii	<i>Conference Committee</i>

3D PRINTING

10915 02	Fabrication of functional nanophotonic devices by multiphoton lithography (Invited Paper) [10915-1]
10915 03	3D photo-responsive optical devices manufactured by advanced printing technologies (Invited Paper) [10915-2]
10915 05	Additive manufacturing of photoluminescent optics [10915-4]

OLEDs

10915 08	Iridium complexes containing nitro-derivatized isoquinoline ligands for photonic applications [10915-7]
----------	---

ORGANIC SENSORS

10915 0I	Comparison of different polymers and printing technologies for realizing flexible optical waveguide Bragg grating strain sensor foils [10915-17]
----------	---

NONLINEAR OPTICS

10915 0N	Understanding photophysics of a high concentration platinum (II) chromophore in epoxy (Invited Paper) [10915-22]
----------	---

PHOTONIC MATERIALS

10915 0R	Practical high refractive index resin usable for near-IR and visible wavelengths (Invited Paper) [10915-26]
----------	---

ORGANIC SEMICONDUCTORS

- 10915 0Y **Space-charge-limited transport in spatially disordered organic materials: a fractional-dimensional approach** [10915-33]

NANOPHOTONICS I

- 10915 11 **Wavelength-selective negative photoresist for photolithography suitable for generating microstructures with up to three distinct height levels** [10915-36]
- 10915 12 **Plasmonic enhancement of absorption in bulk-heterojunction organic solar cells** [10915-37]

NANOPHOTONICS II

- 10915 13 **Growth of organic nonlinear nanowires through a one-drop self-assembly method (Invited Paper)** [10915-38]
- 10915 14 **Enhanced light out-coupling in organic light-emitting diodes (OLED) by patterning the cathode in graded photonic super-crystals** [10915-39]

POSTER SESSION

- 10915 17 **Light-inducing birefringence of organic photoanisotropic materials integrated via covalent bonds** [10915-42]
- 10915 18 **PDMS-based microstructured biosensor** [10915-44]
- 10915 1E **Polymerizable ionic liquids for microstructures fabrication** [10915-51]

Authors

Numbers in the index correspond to the last two digits of the seven-digit citation identifier (CID) article numbering system used in Proceedings of SPIE. The first five digits reflect the volume number. Base 36 numbering is employed for the last two digits and indicates the order of articles within the volume. Numbers start with 00, 01, 02, 03, 04, 05, 06, 07, 08, 09, 0A, 0B...0Z, followed by 10-1Z, 20-2Z, etc.

Ang, Lay Kee, 0Y	Renkel, Rachel N., 0N
Ang, Yee Sin, 0Y	Rola, K., 1E
Argueta-Diaz, Victor, 18	Rumpf, Raymond C., 02
Bambha, Neal K., 08	Schmid, Max C., 11
Cai, Bin, 13	Sharma, Rashi, 02
Camposeo, Andrea, 03	Shensky, William M., III, 08
Chaganava, Irakli, 17	Shi, Jianmin, 08
Cooper, Thomas M., 0N	Slagle, Jonathan E., 0N
Cybińska, J., 1E	Smiglak, M., 1E
Das, Abhijit, 12	Steenhusen, S., 05
Das, Pankaj, 12	Stewart, David J., 0N
D'Elia, Francesca, 03	Sugihara, Okihito, 13
Dhawan, Anuj, 12	Suresh Nair, S., 05
Digaum, Jennefer L., 02	Szukalski, Adam, 03
Ensley, Trenton R., 08	Teigell Beneitez, N., 0I
Ferry, Michael J., 08	Tian, Tian, 13
Fitzpatrick, Brianna, 18	Tomaru, S., 0R
Guan, Shuting, 13	Uttiya, Sureeporn, 03
Haley, Joy E., 0N	Valle, Cesar L., 02
Hassan, Safaa, 14	Van Steenberge, G., 0I
Heinrich, A., 05	Wu, Chenyin, 13
Kamalul Aripin, Nurul Fadhillah, 17	Wussler, Denise, 11
Klein, M., 05	Xia, Chun, 02
Kobulashvili, Irine, 17	Yamauchi, A., 0R
Kohno, H., 0R	Yamauchi, K., 0R
Komorowska, K., 1E	Zajac, A., 1E
Kosimizu, H., 0R	Zhu, Lanfang, 13
Kotz, Frederik, 11	Zubair, Muhammad, 0Y
Krein, Douglas M., 0N	
Kuebler, Stephen M., 02	
Kumar, Kamal, 12	
Kumawat, Uttam, 12	
Lin, Yuankun, 14	
Lowell, David, 14	
Martinez, Noel P., 02	
Martinez-Felipe, Alfonso, 17	
Mattelin, M.-A., 0I	
Michiguchi, M., 0R	
Mishra, Sumakesh, 12	
Missinne, J., 0I	
Mohd Alauddin, Sakinah, 17	
Moore, Autumn E., 08	
Murakoshi, Y., 0R	
Nakamura, J., 0R	
O'Donnell, Ryan M., 08	
Persano, Luana, 03	
Pisignano, Dario, 03	
Portone, Alberto, 03	
Rapp, Bastian E., 11	

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Stephen M. Kuebler, University of Central Florida (United States)
- 3 Biophotonics
Christopher E. Tabor, Air Force Research Laboratory (United States)
- 4 Organic Sensors
Chantal Andraud, Ecole Normale Supérieure de Lyon (France)

- 5 EO Polymers
James G. Grote, Photonics Consultant (United States)
- 6 Nonlinear Optics
Akira Otomo, National Institute of Information and Communications Technology (Japan)
- 7 Photonic Materials
Okihiro Sugihara, Utsunomiya University (Japan)
- 8 Organic Semiconductors
William M. Shensky III, U.S. Army Research Laboratory (United States)
- 9 Nanophotonics I
Eunkyoung Kim, Yonsei University (Korea, Republic of)
- 10 Nanophotonics II
Ileana Rau, University Politehnica of Bucharest (Romania)